Supporting Information

Photocatalytic detoxification of a sulfur mustard simulant by donor-enhanced

porphyrin-based Covalent-Organic Frameworks

Yana Chen^{a,d}, Zewen Shen^a, Yezi Hu^a, Haotian Zhang^a, Lisha Yin^b, Guixia Zhao^{*a}, Guangtong Hai^{*c} and Xiubing Huang^{*d}

^a College of Environmental Science and Engineering, North China Electric Power University, Beijing 102206, P. R. China

^b Institute of Advanced Materials (IAM), School of Flexible Electronics (Future Technologies), Nanjing Tech University (Nanjing Tech), Nanjing, 211816, P. R. China

^c Institute of Zhejiang University-Quzhou, Zhejiang University, Quzhou 324000, China

^d Beijing Advanced Innovation Center for Materials Genome Engineering, Beijing Key Laboratory of Function Materials for Molecule & Structure Construction, School of Materials Science and Engineering, University of Science and Technology Beijing, Beijing 100083, P. R. China

*Corresponding authors

E-mail address: guixiazhao@ncepu.edu.cn (G. Zhao), haigt@zju.edu.cn (G. Hai), xiubinghuang@ustb.edu.cn (X. Huang)

1. General information

All reagents were purchased from commercial suppliers and used without further purification unless stated otherwise. 5,10,15,20-tet-rakis-(4-aminophenyl)-porphyrin (TPH, 98%), 2,5-dihydroxyterephthalaldehyde (DHA, 98%) and 2, 5-dimethoxyterephthalaldehyde (DMA, 98%) were purchased from Jilin Chinese Academy of Sciences-Yanshen Technology Co., Ltd. Terephthaldehyde (DA, 97%), mesitylene (98%), 1,4-Dioxane (99.5%), acetic acid (AcOH, \geq 99.8%), ethanol absolute (99.5%, Water \leq 300 ppm), methanol (99.9%, GC), dimethyl sulfoxide (DMSO, 99.8%), acetonitrile (99.9%), isopropanol (99.9%), 2-Chloroethyl ethyl sulfide (\geq 97%), 1-Chloro-2-(ethylsulfinyl) ethane (\geq 97%) and Tetrahydrofuran (THF, 99%, AR) were all provided by Aladdin.

1.1 Characterizations

Powder X-ray diffraction (PXRD) analyses were performed using a Rigaku SmartLab SE X-ray diffractometer equipped with a Cu Ka source. Small angle X-ray scattering data collected on a Bruker D8 Advance diffractometer was used to correct the deviation with a step size of 0.01°. Fourier transform infrared spectra (FT-IR) were recorded on a SHIMADZU IRTracer-100. BET surface areas were obtained from N₂ adsorption/desorption isotherms collected at 77 K using Micromeritics TriStar II. Scanning electron microscopy (SEM) images were recorded on a Hitachi SU 8100 Scanning Electron Microscope. Solid-state 13C CP/MAS NMR spectra were collected on a BRUKER AVANCE NEO 400WB spectrometer. X-ray photoelectron spectroscopy (XPS) analyses were performed using a Thermo Scientific ESCALAB 250Xi spectrometer, equipped with a monochromatic Al Ka X-ray source (1486.8 eV). Photoelectrochemical experiments measurements were performed on an electrochemical workstation (CHI760E, CHI Instruments, Shanghai, China). Electron paramagnetic resonance (EPR) spectra were recorded at 293 K with a Bruker EMXnano259 spectrometer, operated at 9.62 GHz with 12.59 mW power and modulation at 100 kHz/1 G. By using BaSO₄ as a reflectance standard, the UV-vis DRS of COFs was estimated from 300 to 800 nm by an UV-3600 UV-vis spectrophotometer (Shimadzu, Japan) configured with a diffuse reflectance measurement accessory. Thermogravimetric analysis (TGA) spectra were recorded using a TG/DTA 8122 thermogravimeter under an N₂ atmosphere, with a heating rate of 10 °C min⁻¹ from 30 °C to 800 °C. Photoluminescence (PL) spectra were collected on steady-state fluorescence spectrometer (Horiba Fluoromax-4 spectrophotometer). The conversion, selectivity of CEES was monitored by using a Shimadzu GC-MS (GCMS-QP2020 NX) instrument equipped with a Dielectric barrier discharge plasma detector and

1.2 Electrochemical measurements

The Mott-Schottky plots, photocurrent response and electrochemical impedance of the photo-catalysts were measured on an electrochemical workstation (CHI760E, CHI Instruments, Shanghai, China). A white LED (PLS-LED 100C, PerfectLight) was utilized as the light source and 0.5 M Na₂SO₄ aqueous solution was used as the supporting electrolyte throughout the photocurrent measurements. A platinum wire and Ag/AgCl electrode were used as counter electrode and reference electrode, respectively. To prepare the working electrode, 50 μ L naphthol together with 1 mL ethanol was mixed with 2 mg catalyst. 50 μ L of the mixture was then dipped into ITO, followed by drying in air. Photocurrent measurements were conducted with light on–off cycles and a scan rate of 100 mV s⁻¹. Mott–Schottky measurements were performed under dark conditions at frequencies of 500 Hz, 1000Hz and 1500 Hz. Furthermore, electrochemical impedance spectroscopy (EIS) was conducted under light irradiation at a bias potential of +0.5 V. The potential vs NHE was calculated by using the following Eq:

 $E_{\rm NHE} = E_{\rm Ag/AgCl} + 0.197$



Fig. S1. The schematic diagram for synthesis and structures of COF-H, COF-OH and COF-OMe.



Fig. S2. Fourier transform infrared spectra (FT-IR) of (a) COF-H, (b) COF-OH and (c) COF-OMe.



Fig. S3. N 1s XPS spectra of (a) COF-H and (b) COF-OH.



Fig. S4. C 1s XPS spectra of (a) COF-H, (b) COF-OH and (c) COF-OMe.



Fig. S5. Thermal gravimetric analysis spectrum of COF-H, COF-OH and COF-OMe.



Fig. S6. N₂ sorption isotherms of COF-H, COF-OH and COF-OMe.



Fig. S7. Pore size distribution of (a) COF-H, (b) COF-OH and (c) COF-OMe.



Fig. S8. Mott–Schottky plots of (a) COF-H, (b) COF-OH and (c) COF-OMe at 500 Hz, 1000 Hz and

1500 Hz.



Fig. S9. COF-OMe photocatalyst for selective photocatalytic detoxification of CEES in different solvents. Standard conditions: COFs (5 mg), solvents (5 mL), CEES (0.2 mmol), air, white LED. Reaction time: 3h.



Fig. S10. COF-OMe photocatalyst for selective photocatalytic detoxification of CEES in air and oxygen environments. Standard conditions: COFs (5 mg), CH₃OH (5 mL), CEES (0.2 mmol), white LED. Reaction time: 3h.



Fig. S11. EPR spectra obtained over COF-OMe under white LEDs irradiation and dark condition.



Fig. S12. SEM spectra of COF-OMe before and after reaction.



Fig. S13. PXRD characterization of COF-OMe before and after reaction.



Fig. S14. FT-IR spectra of COF-OMe before and after reaction.



Fig. S15. PXRD characterization COF-H (a) and COF-OH (b); FT-IR spectra of COF-H (c) and COF-OH (d) before and after reaction.

COFs materials	The BET surface areas (m^2/g)	Pore size (nm)
COF-H	211.4	1.91
COF-OH	515.8	1.96
COF-OMe	592.3	1.87

Table S1. The BET surface areas and pore size of COF-H, COF-OH and COF-OMe.

Photocatalysts	Solvent	Atmosphere	light	Conversi on	Ref.
NU-400	methanol	O2	Ultraviolet light	t _{1/2} =10.2 min	1
NU-1000	methanol	O_2	Ultraviolet light	t _{1/2} =6.2 min	2
In ₂ S ₃ /NU-1000	methanol	O_2	Simulated sunlight	3h, 90%	3
NU-1000-PCBA	methanol	O_2	UV (450nm)	t1/2 = 3.5 min	4
Br-BDP@NU-1000	methanol	O_2	green light (325nm)	t1/2 = 2.5 min	5
Ag ₁₂ TpyP	Ethanol	O_2	White light (80nm)	t1/2 = 1.5 min	6
PCN-222	Methanol	O_2	Blue light	t _{1/2} =13mi n	7
TBP⊂ExBox•PSS	methanol	O_2	UV (500nm)	t1/2 =5min	8
I-BDP-POP	MeOH	O_2	green LED (450nm)	t1/2 =3min	9
Fe-TCPP-La	Methanol	O_2	blue LED	t1/2 =2.5min	10
CzBSe-CMP	methanol	O_2	Blue LED lamp (30 W, 460 nm)	1h, 99%	11
MOF/BA/textile	No solvent	Air	Simulated sunlight	t _{1/2} =17.6 min	12
Ag@TAPP-TFPT	Methanol	O_2	Xe light	t1/2 =6.5 min	13
TiO ₂ /PMA SNBs	methanol	Air	xenon lamp	20min, 98.29%	14
PCN-224@TiO ₂	DMF	Air	Simulated sunlight	t _{1/2} =330 min	15
COF-OMe	Methanol	Air	white LED	2h,99%	this work

Materials	Material Cost (\$/g)	Operation Cost (\$/g)	Ref
BTT-TPh-O-COF	228.2	CD ₃ OD (5g/64.4), O ₂ (1atm/0.424)	16
Por-Aminal-COF	698.8	CD ₃ OD (5g/64.4), O ₂ (1atm/0.424)	17
PW12-Ag@COF	97.9	CD ₃ OD (5g/64.4), O ₂ (1atm/0.424)	18
Ag@TAPP-TFPT	127.2	CD ₃ OD (5g/64.4), O ₂ (1atm/0.424)	13
COF-H	39.1	Methanol (5g/0.07) Air (0)	this work
COF-OH	58.2	Methanol (5g/0.07) Air (0)	this work
COF-OMe	53.8	Methanol (5g/0.07) Air (0)	this work

Table S3. The material cost and operation cost of different COFs for CEES photocatalytic oxidation.

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